HPFS® Fused Silica KrF Grade
Semiconductor Optics

HPFS® KrF Grade, Corning code 7980, is a high purity synthetic amorphous silicon dioxide manufactured by flame deposition. The noncrystalline, colorless, silica glass combines a very low thermal expansion coefficient with excellent optical qualities and exceptional transmittance in the deep ultraviolet. KrF Grade was developed for 248 nm lithography systems. In order to satisfy the challenging quality requirements of our customers in leading edge applications such as microlithography, Corning is dedicated to continuous improvement. Our investments in research and development, combined with Corning's quality systems, support our technology leadership position and ensure that we meet our customer's requirements on time, every time.

Quality Grade Selection Chart — HPFS® KrF Grade

Corning defines and certifies the quality of HPFS® glass using two criteria: inclusions and homogeneity grade.

Inclusion Class			Homogeneity [3,4] ppm			
			Grade			
Class	Total Inclusion[1] Cross Section [mm²]	Maximum[2] Size [mm]	AA ≤ 0.5	A ≤ 1	C ≤ 2	F ≤ 5
0	≤ 0.03	0.10	■	■	■	■
1	≤ 0.10	0.28		■	■	■
2	≤ 0.25	0.50			■	■

NOTES:

1. Defines the sum of the cross section in mm^2 of inclusions per 100 cm^3 of glass. Inclusions with a diameter ≤ 0.10 mm are disregarded.
2. Refers to the diameter of the largest single inclusion.
3. Index homogeneity: the maximum index variation (relative), measured over the clear aperture of the blank.
4. Index homogeneity is certified using an interferometer at 632.8 nm. The numerical homogeneity is reported as the average through the piece thickness. Blanks with a diameter up to 450 mm can be analyzed over the full aperture. Larger parts can be analyzed using multiple overlapping apertures. The minimum thickness for index homogeneity verification is 20 mm.

For thinner parts, the parent piece is certified.

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Mechanical and Thermal Properties:

Unless otherwise stated, all values @ 25°C

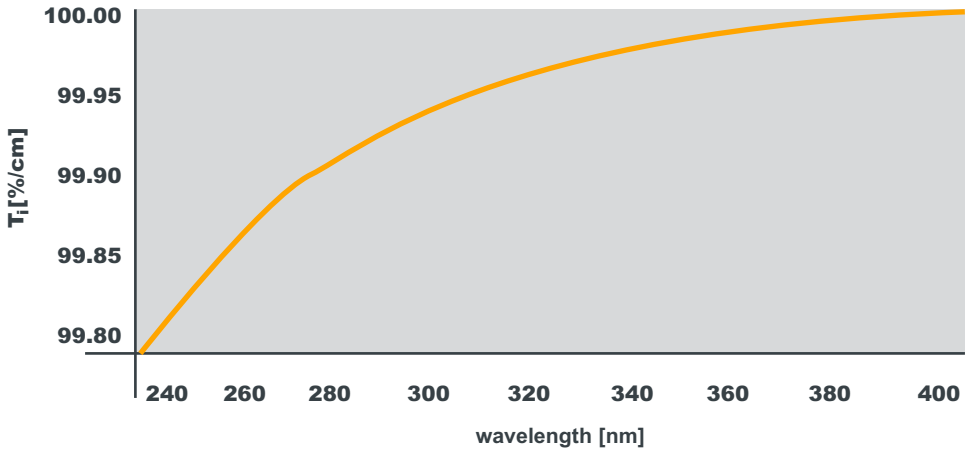
Elastic (Young's) Modulus	72.7 GPa
Shear Modulus	31.4 GPa
Modulus of Rupture, abraded	52.4 MPa
Bulk Modulus	35.4 GPa
Poisson's Ratio	0.16
Density	2.201 g/cm^3
Knoop Hardness (100 g load)	522 kg/mm^2

Softening Point		1585°C ($10^{7.6}$ poises)
Annealing Point		1042°C (10^{13} poises)
Strain Point		893°C ($10^{14.5}$ poises)
Thermal Conductivity		1.30 W/m K
Thermal Diffusivity		0.0075 cm^2/s
Average C.T.E.	0.52 ppm/K	5°C-35°C
	0.57 ppm/K	0°C-200°C
	0.48 ppm/K	-100°C-200°C

Chemical Durability and Impurities

Solution		Time	Weight Loss [mg/cm^2]	Impurities
5% HCL by weight	@ 95°C	24 h	< 0.010	OH content (by weight): 800-1000 ppm
5% NaOH	@ 95°C	6 h	0.453	Impurities other than OH: ≤ 500 ppb
0.02N NA_2CO_3	@ 95°C	6 h	0.065	
0.02N H_2SO_4	@ 95°C	24 h	< 0.010	
Deionized H_2O	@ 95°C	24 h	0.015	
10% HF by weight	@ 25°C	20 m	0.230	
10% NH_4F*HF by weight	@ 25°C	20 m	0.220	

Internal Transmittance: Code 7980 KrF Grade



HPFS® KrF Grade is certified to meet $T_i \geq 99.8\%/cm$ @248 nm when measured through a polished, uncoated sample.

A typical internal transmittance curve for HPFS® KrF Grade fused silica is shown here.

Refractive Index and Dispersion

Data in 22ºC in 760mm Hg dry nitrogen gas

Wavelength [air] λ [nm]	Refractive Index *2 n	Thermal Coefficient Δn/ΔT*3 (ppm/K)
1128.64	1.448870	9.6
1064.00	1.449633	9.6
1060.00	1.449681	9.6
1013.98 n_t	1.450245	9.6
852.11 n_s	1.452469	9.7
706.52 n_r	1.455149	9.9
656.27 n_C	1.456370	9.9
643.85 $n_{C'}$	1.456707	10.0
632.80 n_{He-Ne}	1.457021	10.0
589.29 n_D	1.458406	10.1
587.56 n_d	1.458467	10.1
546.07 n_e	1.460082	10.2
486.13 nF	1.463132	10.4
479.99 $n_{F'}$	1.463509	10.4
435.83 n_g	1.466701	10.6
404.66 n_h	1.469628	10.8
365.01 n_i	1.474555	11.2
334.15	1.479785	11.6
312.57	1.484514	12.0
308.00	1.485663	12.1
248.30	1.508433	14.2
248.00	1.508601	14.2
214.44	1.533789	17.0
206.20	1.542741	18.1
194.17	1.559012	20.4
193.40	1.560208	20.5
193.00	1.560841	20.6
184.89	1.575131	22.7

Polynomial Dispersion Equation Constants*1

A0	2.104025406
A1	$-1.456000330 \times 10^{-4}$
A2	$-9.049135390 \times 10^{-3}$
A3	$8.801830992 \times 10^{-3}$
A4	$8.435237228 \times 10^{-5}$
A5	$1.681656789 \times 10^{-6}$
A6	$-1.675425449 \times 10^{-8}$
A7	$8.326602461 \times 10^{-10}$

Sellmeier Dispersion Equation Constants *2

B1	0.68374049400
B2	0.42032361300
B3	0.58502748000
C1	0.00460352869
C2	0.01339688560
C3	64.49327320000

Δn/ΔT Dispersion Equation Constants *3

C0	9.390590
C1	0.235290
C2	-1.318560 x 10-3
C3	3.028870 x 10-4

Other Optical Properties

ν_d	67.79
ν_e	67.64
$n_F - n_C$	0.006763
$n_{F'} - n_{C'}$	0.006802
Stress Coefficient	35.0 nm/cm MPa
Striae	ISO 10110-4 Class 5/Thickness Direction
Birefringence	≤ 1 nm/cm, lower specifications available

*1 Polynomial Equation: $n^2 = A_0 + A_1 \lambda^4 + A_2 \lambda^2 + A_3 \lambda^{-2} + A_4 \lambda^{-4} + A_5 \lambda^{-6} + A_6 \lambda^{-8} + A^7 \lambda^{-10}$ with λ in µm
*2 Sellmeier Equation: $n^2-1 = B_1 \lambda^2/(\lambda^2-C_1) + B_2 \lambda^2/(\lambda^2-C_2) + B_3 \lambda^2/(\lambda^2-C_3)$ with λ in µm
*3 Δn/ΔT Equation (20-25ºC) = $C_0 + C_1 \lambda^{-2} + C_2 \lambda^{-4} + C_3 \lambda^{-6}$ with λ in µm

Resistance to Laser Damage

Samples of HPFS® KrF Grade are regularly tested for induced absorption at Corning's Metrology Laboratory, Sullivan Park Research Center, to maintain the high standards to which Corning is committed.

We are here to help you specify the best product for your application. For further information, please contact:

Worldwide Accessibility

United States/Canada Sales Office
Corning Incorporated
Semiconductor Optics Business
334 County Route 16
Canton, NY 13617

t: 315.379.3600
f: 315.379.3317
e-mail: hpfs@corning.com

European Sales Office
Corning GmbH
Corning International
Abraham-Lincoln-Strasse 30
D-65189 Wiesbaden, Germany

t: 49.611.7366.100
f: 49.611.7366.143
e-mail: CIgermany@corning.com

Asia Sales Offices
Corning International K.K.
No. 35 Kowa Building, 3F
14-14, Akasaka 1-chome
Minato-Ku, Tokyo 107-0052
Japan

t: 81.3.3586.1052
f: 81.3.3587.0906

Corning International
1 Kim Seng Promenade
#12-12
GreatWorld City
West Tower
Singapore 237994
Republic of Singapore

t: 65.733.6511
f: 65.861.7310

Corning Korea Company Ltd.
10th Floor, Kukje Center Bldg.
191, Hangangro 2-Ka
Yongsan-Ku
Seoul, Korea 140-702

t: 82.2.796.9500
f: 82.2.796.9300

Corning Glass Taiwan Co. Ltd.
Room # 1023, 12F
No. 205 Tun Hua North Road
Taipei, Taiwan

t: 886.2.2716.0338
f: 886.2.2716.0339

Australia Sales Office
Corning International Australia
Suite 18
12, Tryon Road
Lindfield, NSW 2070
Australia

t: 61.2.9416.0492
f: 61.2.9416.0493

World Headquarters
Corning Incorporated
One Riverfront Plaza
Corning, New York 14831-0001

t: 607.974.9000

Corning Incorporated

One Riverfront Plaza
Corning, NY 14831
607.974.9000

www.corning.com

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